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A Simple Sol-Gel Processing for the Development of High-Temperature Stable Photoactive Anatase Titania

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A method for the preparation of anatase TiO₂, which is stable to a temperature as high as 900 °C, without using any complex cationic dopants is presented. The synthetic procedure involves the reaction of titanium tetraisopropoxide (TTIP) with trifluoroacetic acid (TFA) followed by hydrolysis and sol-gel conversion to the xerogel and further calcination. The retention of the anatase phase to high temperatures can be attributed to the presence of small amounts of fluorine in the lattice, which is gradually removed between 500 and 900 °C as confirmed by X-ray photoelectron spectroscopy and Fourier transform infrared spectroscopic analysis. Samples prepared with a 1:16 TTIP/TFA composition calcined at 900 °C showed significantly higher photocatalytic activity compared to the *control* sample, standard commercial photocatalyst Degussa P25, and samples prepared using acetic acid and oxalic acid. The high-temperature anatase phase stability, determined by X-ray diffraction and Raman spectroscopy, coupled with its high crystallinity, microporosity, and minimal oxygen vacancy contributes to improved photocatalytic activity.

Introduction

Titania (TiO₂) is well-known for its applications in highrefractive optics,¹ oxide semiconductors,² oxygen sensors,³ photovoltaics,⁴ photocatalysis,⁵ and pigments.⁶ A particular interest is in the development of TiO₂ anatase coatings for 29 self-cleaning and hygienic applications,⁷ where it is expected 30 that the anatase form of TiO_2 should be most effective.⁸ A 31 recent commercial application has shown the effectiveness 32 of such a photoactive silver-doped titania coating.9 However, 33 as the processing temperature required for this material was 34900 °C, this coating contained 8% anatase and 92% rutile. 35 The anatase-to-rutile transformation in synthetic titania 36 usually occurs at temperatures in the range of 600-700 37 °C.^{10,11} Therefore, there is a need for procedures which will 38 produce anatase-phase TiO₂ which is stable at 900 °C. This 39 challenge has been met in some cases by the addition of 40 cationic dopants.¹² Except for a few cases,¹³ however, the 41 photoactivity of the cation-doped TiO_2 is decreased due to 42

- (8) Kamat, P. V. Chem. Rev. 1993, 93, 267.
- (9) Machida, M.; Norimoto, K.; Kimura, T. J. Am. Ceram. Soc. 2005, 88, 95.
- (10) (a) Kumar, K. N. P.; Keizer, K.; Burggraaf, A. J.; Okubo, T.; nagamoto, H.; Morooka, S. *Nature* **1992**, *358*, 48. (b) Kumar, S. R.; Pillai, S. C.; Hareesh, U. S.; Mukundan, P.; Warrier, K. G. K. *Mater. Lett.* **2000**, *43*, 286. (c) Kumar, S. R.; Suresh, C.; Vasudevan, A. K.; Suja, N. R.; Mukundan, P.; Warrier, K. G. K. *Mater. Lett.* **1999**, *38*, 161.
- (11) (a) Yin, S.; Aita, Y.; Komatsu, M.; Sato, T. J. Eur. Ceram. Soc. 2006, 26, 2735. (b) Gandhe, A. R.; Naik, S. P.; Fernades, J. B. Micropor. Mesopor. Mater. 2005, 87, 103. (c) Cheng, P.; Qiu, J.; Gu, M.; Shangguan, W. Mater. Lett. 2004, 58, 3751.

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 ⁽a) Wang, X. D.; Neff, C.; Graugnard, E.; Ding, Y.; King, J. S.; Pranger, L. A.; Tannenbaum, R.; Wang, Z. L.; Summers, C. J. Adv. Mater. 2005, 17, 2103. (b) King, J. S.; Graugnard, E.; Summers, C. J. Adv. Mater. 2005, 17, 1010. (c) Prokes, S. M.; Gole, J. L.; Chen, X. B.; Burda, C.; Carlos, W. E. Adv. Funct. Mater. 2005, 15, 161.

⁽²⁾ Hoffmann, M. R.; Martin, S. T.; Choi, W.; Bahnemann, D. W. Chem. Rev. 1995, 95, 69.

 ^{(3) (}a) Watson, J.; Ihokura, K. *Mater. Res. Soc. Bull.* 1999, *6*, 14 and articles thereof. Materials". (b) Zhu, Y.; Shi, J.; Zhang, Z.; Zhang, C.; Zhang, X. *Anal. Chem.* 2002, *74*, 120. (c) Morris, D.; Egdell, R. G. *J. Mater. Chem.* 2001, *11*, 3207.

^{(4) (}a) O'Regan, B.; Gratzel, M. A. *Nature* **1991**, *353*, 737. (b) Park, N.-G.; van de Lagemaat, J.; Frank, A. J. J. Phys. Chem. B **2000**, *104*, 8989. (c) Ito, S.; Zakeeruddin, S. M.; Baker, R. H.; Liska, P.; Charvet, R.; Comte, P.; Nazeeruddin, M. K.; Péchy, P.; Takata, M.; Miura, H.; Uchida, S.; Grätzel, M. Adv. Mater. **2006**, *18*, 1202.

^{(5) (}a) Seery, M. K.; George, R.; Floris, P.; Pillai, S. C. J. Photochem. Photobiol., A 2007, 189, 258. (b) Fujishima, A.; Honda, K. Nature 1972, 238, 37. (c) Yu, J. C.; Yu, J.; Ho, W.; Zhang, L. Chem. Commun. 2001, 1942. (d) Linsebigler, A. L.; Lu, G.; Yates, J. T., Jr. Chem. Rev. 1995, 95, 735. (e) Zhang, Z. B.; Wang, C. C.; Zakaria, R.; Ying, J. Y. J. Phys. Chem. B 1998, 102, 10871. (f) Anpo, M.; Shima, T.; Kodama, S.; Kubokawa, Y. J. Phys. Chem. 1987, 91, 4305. (g) Fujishima, A.; Rao, T. N.; Tryk, D. A. J. Photochem. Photobiol., C 2000, 1, 1.

 ^{(6) (}a) Feldmann, C. Adv. Mater. 2001, 13, 1301. (b) Feldmann, C.; Jungk, H. O. Angew. Chem., Int. Ed. 2001, 40, 359.

^{(7) (}a) Wang, R.; Hashimoto, K.; Fujishima, A.; Chikuni, M.; Kojima, E.; Kitamura, A.; Shimohigoshi, M.; Watanabe, T. *Nature* 1997, 388, 431. (b) Hashimoto, K.; Irie, H.; Fujishima, A.; Jpn. J. Appl. Phys., Part 1 2005, 44, 8269. (c) Zhang, X.-T.; Sato, O.; Taguchi, M.; Einaga, Y.; Murakami, T.; Fujishima, A. Chem. Mater. 2005, 17, 696.

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its thermal instability or an increase in charge carrier
 recombination centers.¹⁴

High crystallinity and suitable surface properties (acces-45 sible surface area, porosity, and pore volume) are the other 46 key factors that contribute to the photocatalytic activity. A 47possible high temperature heat treatment may be useful to 48 accomplish these features, provided the anatase phase is 49 stable against heat treatment. In this context, the possibilities 50 of sulfate-modified anatase TiO2 systems have been ex-51 plored.¹⁵ Thus, Colon et al. have prepared a highly crystalline 52TiO₂ powder with good photocatalytic activity for the 53destruction of phenol at 700 °C by sulfating a hydrous titania 54gel.^{15a} They attributed the activity to minimal crystal defects 55 56evolved after the elimination of sulfate species. Similarly, Zhang et al. extended the anatase phase stability of TiO₂ up 57to 600 °C (873 K) by adding a small amount of sulfate 58 species into the hydrolysis product of TiCl₄.^{15b} As part of a 59 program to develop high-temperature stable photoactive 60 titania materials, we have recently prepared a nitrogen-doped 61 62 titania which was stable up to 800 °C.¹⁶ All these reports, however, involve a precipitate route synthesis which cannot 63 be used for making thin films by dip-coating or spin-coating 64 techniques. A sol-gel route should, on the other hand, be 65 more effective in terms of the homogeneity of the sol, which 66 67 is advantageous over the other techniques, and both powders and coatings can be prepared by a one-step sol-gel process. 68 Here, we report a simple and effective sol-gel method to 69 synthesize high-temperature stable (900 °C), photoactive 70 71 anatase TiO₂, which we believe should be useful in the preparation of smart coatings for ceramics in hygienic 72applications. 73

The preparation method involves the modification of a 74precursor, titanium tetraisopropoxide (TTIP), with trifluo-7576 roacetic acid (TFA) followed by hydrolysis, gelation, drying, and heat treatment to achieve nanosized TiO₂. High-77 temperature heat treatment facilitates the preparation of 7879 highly crystalline anatase TiO₂ with minimal oxygen vacancy concentration. Methylene blue (MB) degradation experiments 80 81 under UV light (365 nm) show its high activity, which is better than that of the commercial TiO₂, Degussa P25. In 82 order to compare and deduce the effectiveness of this 83 preparative route, samples such as acetic acid (HOAc)-84

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modified TiO_{2} ,¹⁷ oxalic acid (OxA)-modified TiO_{2} ,¹⁸ and a so control TiO_{2} (prepared without any modifier) have also been produced by similar procedures. The factors influencing the photocatalytic activity are discussed. 88

Experimental Section

In a typical synthesis {to prepare a sol (Ti-16TFA) with 1:16:4 90 (molar ratio) TTIP/TFA/H2O}, 2.5 mL of TTIP was added to 4.4 91 mL of a TFA solution in a glass beaker under stirring. Subsequently, 92 0.60 mL of Millipore water was added dropwise into the clear 93 solution formed, and the beaker was sealed using a parafilm, and 94 stirring was continued for a further 1 h. After 24 h of aging at 95 room temperature (20 °C), the sol was dried at 90 °C in an air 96 oven to obtain the gel. The gel was then calcined at different 97 temperatures such as 300, 500, 600, 700, 800, 900, and 1000 °C at 98 a heating rate of 5 °C per minute and held at these temperatures 99 for 2 h (samples Ti-16TFA-300 to Ti-16TFA-1000). Sols with 1:1, 100 1:4, 1:8, 1:12, and 1:32 Ti/TFA ratios were also prepared and 101 converted by a similar method to TiO₂ gels. Similar compositions 102 of Ti/HOAc/H2O samples were also prepared for comparison. Ti/ 103 OxA/H2O samples were prepared by dissolving oxalic acid crystals 104 in 125 mL of absolute ethanol before the addition of TTIP. A 105standard (control-TiO₂) was prepared by adding 0.60 mL of 106 Millipore water to 2.5 mL of a TTIP solution under stirring. 107

Characterization Techniques.Powder XRD patterns were108recorded with a Siemens D 500 X-ray diffractometer in the 2θ range109 $20-70^{\circ}$ using Cu K α radiation. The anatase content in the sample110was estimated using the Spurr equation:111

$$F_{\rm A} = 100 - \left(\frac{1}{1 + 0.8[I_{\rm A}(101)/I_{\rm R}(110)]}\right) 100 \tag{1}$$

where F_A is the mass fraction of anatase in the sample and I_A and 112 $I_{\rm R}$ are the integrated intensities of the main peaks of anatase (101) 113 and rutile (110), respectively. Crystallite sizes were calculated from 114 the peak widths using the Scherrer equation $\Phi = k\lambda/(\beta \cos \theta)$, 115where Φ is the crystallite size, k is the shape factor (a value of 0.9 116 was used in this study), λ is the X-ray radiation wavelength (1.546) 117 Å for Cu K α), and β is the line width at half-maximum height of 118 the main intensity peak after subtraction of the equipment broaden-119 ing. Room-temperature Raman spectra were recorded with a 120 Renishaw 1000 micro-Raman system equipped with an Ar⁺ ion 121laser (Laser Physics Reliant 150 Select Multi-Line) with a typical 122 laser power of \sim 3 mW in order to avoid excessive heating. The 123 50×-magnifying objective of the Leica microscope focused the 124 beam into a spot of about 1 μ m in diameter. Fourier transform 125infrared spectroscopy (FTIR) spectra of the samples in KBr pellets 126were recorded using a Spectrum GX FTIR spectrometer in the range 127 4000-370 cm⁻¹. The BET specific surface area was measured using 128 Nova Station A surface area analyzer (Quantachrome Instruments 129 version 2.1). The pore size distribution was obtained using the 130 Horvath-Kawazoe method.19 131

Diffuse reflectance spectra (DRS) of the samples were recorded132using a Perkin-Elmer Lambda 900 UV/Vis/NIR spectrometer with133an integrated sphere attachment. Sample pellets were prepared using134

^{(12) (}a) Choi, W.; Termin, A.; Hoffmann, M. R. Angew. Chem. 1994, 106, 1148. (b) Wang, C. Y.; Bahnemann, D. W.; Dohrmann, J. K. Chem. Commun. 2000, 1539. (c) Choi, W.; Termin, A.; Hoffmann, M. R. Angew. Chem., Int. Ed. Engl. 1994, 33, 1091. (d) Liu, Y.; Liu, C. Y.; Rong, Q. H.; Zhang, Z. Appl. Surf. Sci. 2003, 220, 7. (e) Zhang, Y. H.; Zhang, H. X.; Xu, Y. X.; Wang, Y. G. J. Mater. Chem. 2003, 13, 2261. (f) He, J.; Ichinose, I.; Fujikawa, S.; Kunitake, T.; Nakao, A. Chem. Mater. 2002, 14, 3493.

^{(13) (}a) Karakitsou, K. E.; Verykios, X. E. J. Phys. Chem. 1993, 97, 1184.
(b) Yamashita, H.; Ichihashi, Y.; Takeuchi, M.; Kishiguchi, S.; Anpo, M. J. Synchrotron Radiat. 1999, 6, 451.

 ^{(14) (}a) Choi, W.; Termin, A.; Hoffmann, M. R. J. Phys. Chem. 1994, 98, 13669. (b) Hermann. J. M.; Disdier, J.; Pichat, P. Chem. Phys. Lett. 1984, 108, 618.

^{(15) (}a) Colon, G.; Hidalgo, M. C.; Navio, J. A. *Appl. Catal., B.* 2003, *45*, 39. (b) Zhang, Q.; Gao, L.; Guo, J. *J. Eur. Ceram. Soc.* 2000, *20*, 2153. (c) Yang, Q.; Xie, C.; Xu, Z.; Gao, Z.; Du, Y. *J. Phys. Chem. B* 2005, *109*, 5554. (d) Bokhimi, X.; Morales, A.; Novaro, O.; Lopez, T.; Chimal, O.; Asomoza, M.; Gomez, R. *Chem. Mater.* 1997, *9*, 2616.

 ⁽¹⁶⁾ Pillai, S. C.; Periyat, P.; George, R.; McCormack, D. E.; Seery, M. K.; Hayden, H.; Colreavy, J.; Corr, D.; Hinder, S. J. J. Phys. Chem. C 2007, 111, 1605.

 ^{(17) (}a) Sibu, C. P.; Kumar, S. R.; Mukundan, P.; Warrier, K. G. K. *Chem. Mater.* **2002**, *14*, 2876. (b) Suresh, C.; Biju, V.; Mukundan, P.; Warrier, K. G. K. *Polyhedron* **1998**, *17*, 3131.

⁽¹⁸⁾ Bersani, D.; Antonioli, G.; Lottici, P. P.; Lopez, T. J. Non-Cryst. Solids **1998**, 232–234, 175.

^{(19) (}a) Horvath, G.; Kawazoe, K. J. Chem. Eng. Jpn. 1983, 16, 470. (b) Everett, D. H.; Powl, J. C. J. Chem. Soc., Faraday Trans. 1976, 72, 619. (c) Terzyk, A. P; Gauden, P. A. Colloids Surf., A 2001, 177, 57. (d) Roziere, J.; Brandhorst, M.; Dutartre, R.; Jacquin, M.; Jones, J. D.; Vatse, P.; Zajac, J. J. Mater. Chem. 2001, 11, 3264.

a 4 mm die after thoroughly mixing the powder samples with KBr.²⁰
The band gaps were calculated by extrapolating the lower wavelength cutoff region.

X-ray photoelectron spectroscopy (XPS) analyses were per-138 formed on a Thermo VG Scientific (East Grinstead, U.K.) Sigma 139 Probe spectrometer. The instrument employs a monochromated Al 140 K α X-ray source ($h\nu = 1486.6$ eV), which was used at 140 W. 141 142The area of analysis was approximately 500 μ m in diameter for 143 the samples analyzed. For survey spectra, a pass energy of 100 eV and a 0.4 eV step size were employed. For C_{1s} and Ti_{2p} high-144 resolution spectra, a pass energy of 20 eV and a 0.1 eV step size 145 were used. For O1s high-resolution spectra, a pass energy of 20 eV 146 and a 0.2 eV step size were used. For F_{1s} and N_{1s} high-resolution 147 148spectra, a pass energy of 50 eV and a step size of 0.2 eV were used. Charge compensation was achieved by using a low-energy 149 electron flood gun. Quantitative surface chemical analyses were 150 calculated from the high-resolution core-level spectra, following 151 152 the removal of a nonlinear Shirley background. The manufacturer's Avantage software was used, which incorporates the appropriate 153154sensitivity factors and corrects for the electron energy analyzer 155 transmission function.

156 Photoactivity Study. Photoactivity experiments were conducted 157 by measuring the extent of degradation of an organic dye, methylene 158 blue, in the presence of TiO_2 . For this, 1.5 mg of TiO_2 powder was first dispersed in 4 mL of Millipore water in a UV cell. The 159 suspension was then ultrasonicated for 10 min. A total of 0.1 mL 160 of 2×10^{-3} M MB was then added to the suspension. The samples 161 were irradiated under UV light using a Luzchem UV chamber 162 163 (Canada) consisting of 10 8-W Hitachi-II tubes (wavelength 365 164 nm). The absorbance maximum of MB (664 nm) was measured after each interval of light irradiation from 0 min up to 85 min. 165 The kinetics of the MB degradation were analyzed as reported 166 previously.5a,16 Photodegradation experiments had also been con-167 ducted in Irish sunlight on the 24th of July, 2006. 168

Results

The preparation method involves the reaction of TTIP with TFA followed by hydrolysis, gelation, drying at 90 °C, and heating (500–900 °C) to give nanosized TiO₂. The chemical sequence may be represented as shown in Scheme 1.

Scheme 1. Chemical Sequence of TFA Modified Sol-Gel Process

 $Ti(OR)_4 + CF_3COOH (excess)$ \longrightarrow $Ti(OOCCF_3)_4 + 4 ROH$

$$\begin{array}{c} 90 \ ^{\circ}\text{C} \\ \hline \text{Ti}(\text{OOCCF}_3)_4 \ + \ \text{H}_2\text{O} \end{array} \xrightarrow{90 \ ^{\circ}\text{C}}$$

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$$Ti(OOCCF_{3})_{4,x}(OH)_{x} \xrightarrow{500 \text{ °C}} TiO_{2,x}F_{2x} \xrightarrow{900 \text{ °C}} TiO_{2,x}F_{2x}$$

Ti(OOCCF3)4-x (OH)x

It is notable that, in contrast to the Ti-16HOAc system, 174where gelation occurs immediately upon the addition of water 175at room temperature (20 °C), the Ti-16TFA mixture (Sup-176porting Information 1) does not gel, indicating that the rate 177 of hydrolysis is considerably lower for the latter system. 178 Indeed, this is further evident from the longer shelf life of 179 the Ti-16TFA sol samples at room temperature (20 °C), and 180 the xerogel is only formed upon heating to 90 °C. These 181 materials have been found to be extremely robust in that 182 they have remained stable in their prepared form for in excess 183 184 of 1 year.

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Figure 1. XRD patterns of various Ti-TFA samples (a) calcined at 700 $^{\circ}$ C and (b) calcined at 900 $^{\circ}$ C. (A, anatase; R, rutile).

 Table 1. Crystalline Phases and Weight Percentages of Anatase and Rutile (A:R) Determined from XRD

sol used for preparation	% anatase (A):% rutile (R) at specified temperatures (error ± 5%)				
	600 °C	700 °C	800 °C	900 °C	1000 °C
Ti-32TFA	100:0	100:0	100:0	96:4	0:100
Ti-16TFA	100:0	100:0	100:0	100:0	0:100
Ti-12TFA	100:0	100:0	100:0	92:8	0:100
Ti-8TFA	100:0	100:0	90:10	43:57	0:100
Ti-4TFA	100:0	98:2	83:17	39:61	0:100
Ti-1TFA	100:0	82:18	25:75	0:100	0:100
Ti-16OxA	100:0	13:87	0:100	0:100	0:100
Ti-16HOAc	24:76	0:100	0:100	0:100	0:100
control TiO2	18:82	0:100	0:100	0:100	0:100

X-ray Diffraction Analysis. The phase evolution of the 185samples has been followed by the powder X-ray diffraction 186 (XRD) technique. The XRD patterns of the samples calcined 187 at 700 and 900 °C are presented as Figure 1a and b, 188 respectively. The percentage anatase and rutile contents 189 calculated using the Spurr equation are presented in Table 190 1. It may be noted that a 100% anatase TiO₂ was observed 191 at a temperature as high as 900 °C for the sample prepared 192 from the Ti-16TFA sol. The intense anatase (101) peak is 193 indicative of its high crystallinity compared to the low-194 temperature calcined samples. By contrast, even at 700 °C, 195 the *control* and HOAc-modified TiO₂ samples were 100% 196

⁽²⁰⁾ Gauglitz, G.; Vo-Dinh, T. *Handbook of Spectroscopy*; Wiley-VCH: New York, 2003; Vol. 1, p 97.

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Figure 2. Raman spectra of (a) *control* TiO_2 -700, (b) Ti-16HOAc-700, and (c) Ti-16TFA-900 (A, anatase; R, rutile) registered at 514 nm excitation wavelength.

rutile, while the OxA-modified TiO2 showed a mixed phase 197 198 composition with 13% anatase and 87% rutile. For the 199 samples prepared with lower molar ratios of TFA, the anatase-to-rutile transformation commences just below 700 200 °C for the Ti-1TFA sample (Figure 1a) and is completely 201 transformed to rutile at 900 °C. On the other hand, with the 202 Ti-8TFA sample, the conversion to rutile only starts at ca. 203 800 °C, and at 900 °C the sample contained ca. 57% rutile. 204 All the samples show a 100% rutile phase at 1000 °C 205(Supporting Information 2). 206

207 Raman spectroscopy, being a more sensitive technique to detect even traces of a compound, was also employed for 208 phase analysis (Figure 2). Ti-16TFA-500 (not shown here) 209 and Ti-16TFA-900 gave spectral bands corresponding to 210anatase TiO₂ (144, 197, 395, 514, and 638 cm⁻¹).²¹ The 211 212 control TiO₂ and Ti-16HOAc samples on the other hand were converted to rutile at 700 °C (bands at 143, 233, 447, and 213 610 cm^{-1}).²² 214

N2 adsorption studies were conducted to examine the effect 215of calcination on the textural properties. Ti-16TFA-900 216showed a surface area of 20 $m^2 g^{-1}$ compared to that of the 217control TiO₂ which was $<1 \text{ m}^2 \text{ g}^{-1}$ at 900 °C. The pore 218219 radius measured using the Horvath-Kawazoe method indicated the formation of a microporous network (9.273 Å) for 220 Ti-16TFA-900, while the control TiO₂-900 was almost 221 nonporous. The adsorption isotherm of Ti-16TFA-900 (Sup-222porting Information 3) also showed the presence of a 223 predominantly microporous network. The dramatic change 224225in the surface area and porosity values could be attributed to the incorporation of F atoms. It is reported that F 226

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incorporation into the silica network creates nanovoids.²³ The 227 evolution of microporosity in the present system is therefore 228 ascribed to a similar effect. 229

Diffuse reflectance spectral analyses were performed to 230 investigate the effect of calcination on the optical properties 231of different powder samples (Supporting Information 4). 232 From such spectra, the band gap for the materials was 233 calculated. A band gap of 3.02 eV is obtained for the control 234TiO₂-700 and -900 samples, which corroborate with the 235 reported data for rutile TiO2.^{2,5d} The Ti-16TFA-700 and -900 236 samples on the other hand showed a band gap of 3.28 eV. 237Furthermore, a steady decrease in the percent reflectance in 238 the higher wavelength side of the spectrum demonstrates the 239 oxygen vacancy concentration of samples.²⁴ Such a sloping 240 baseline observed for Ti-16TFA-700 may be indicative of 241 the presence of oxygen vacancies. Ti-16TFA-900, on the 242other hand, showed little change in baseline, consistent with 243a sample relatively free of this defect (with minimal oxygen 244vacancy). 245

To determine the role of TFA and especially whether any 246 fluorine can be observed after calcination, XPS has been 247performed on the Ti-16TFA samples calcined at 500, 700, 248 800, 900, and 1000 °C. Figure 3a and b present the XPS 249 high-resolution spectra for F1s of Ti-16TFA-500 and Ti-25016TFA-900 samples, respectively. The photoelectron peak 251 located at 684.5 eV for Ti-16TFA-500 and Ti-16TFA-700 252(Supporting Information 5) is ascribed to the F1s species of 253F adsorbed on TiO₂.²⁵ Concentrations of 0.5 atom % F and 2540.3 atom% F are determined for the Ti-16TFA-500 and Ti-25516TFA-700 samples, respectively. Similar peaks are however 256absent in the Ti-16TFA-800 (Supporting Information 5) and 257Ti-16TFA-900 samples. However the TGA pattern obtained 258for the Ti-16TFA gel shows a small percent loss of mass up 259to 800 °C. By contrast, the weight loss appeared to be 260 complete at ~400 °C for the Ti-16HOAc and the control 261 TiO₂ gels (Supporting Information 6). 262

The presence of lattice F atoms is represented by a peak 263located at 688 eV in XPS.²⁶ Such a peak could be observed 264 only for the Ti-16TFA-500 and Ti-16TFA-700 samples. XPS 265is a surface technique whose analysis depth is 4-5 nm, and 266 therefore the presence of deep lattice F atoms (in Ti-16TFA-267 800 and Ti-16TFA-900 samples, where the surface and near-268 surface F atoms would be completely eliminated) may not 269 be observable using this technique. By contrast, FTIR should 270 be able to probe the presence of Ti-F bonds in the sample. 271Figure 4 presents the FTIR spectra of the *control* TiO₂-500 272and the various Ti-16TFA samples. A weak band at 1080 273cm⁻¹ is observed for the Ti-16TFA-500 sample, consistent 274with the observation by Li et al. in the Mg-F system, but a 275similar band could not be detected in any other samples, and 276

^{(21) (}a) Music, S.; Gotic, M.; Ivanda, M.; Popovic, S.; Turkovic, A.; Trojko, R.; Sekulic, A.; Furic, K. *Mater. Sci. Eng.*, B 1997, 47, 33. (b) Ivanda, M.; Music, S.; Popovic, S.; Gotic, M. J. Mol. Struct. 1999, 480, 645.
(c) Huang, P. J.; Chang, H.; Yeh, C. T.; Tsai, C. W. *Thermochim. Acta* 1997, 297, 85. (d) Choi, H. C.; Jung, Y. M.; Kim, S. B. Vib. Spectrosc. 2005, 37, 33.

^{(22) (}a) Pawlewicz, W. T.; Exarhos, G. J.; Conaway, W. E. Appl. Optics 1983, 22, 1837. (b) Peng, X.; Wang, J.; Thomas, D. F.; Chen, A. Nanotechnology 2005, 16, 2389. (c) Parker, J. C.; Segel, R. W. Appl. Phys. Lett. 1990, 57, 943. (d) Capwell, R. J.; Spagnolo, F.; De Sesa, M. A. Appl. Spectrosc. 1972, 26, 537. (e) Lei, Y.; Zhang, L. D.; Meng, G. W.; Li, G. H.; Zhang, X. Y.; Liang, C. H.; Chen, W.; Wang, S. X. Appl. Phys. Lett. 2001, 78, 1125. (f) Serpone, N.; Lawless, D.; Khairutdinov, R. J. Phys. Chem. 1995, 99, 16646.

^{(23) (}a) Altshuler, S.; Chakk, Y.; Rozenblat, A.; Cohen, A. *Microelectron.* Eng. 2005, 80, 42. (b) Pankov, V.; Alonso, J. C.; Ortiz, A. J. Appl. Phys. 1999, 86, 275. (c) Kim, J.; Chung, J. C.; Sheen, D.; Sohn, Y. J. Appl. Phys. 2004, 96, 1435.

⁽²⁴⁾ Vratny, F.; Micale, F. Trans. Faraday Soc. 1963, 59, 2739.

 ^{(25) (}a) Li, D.; Haneda, H.; Hishita, S.; Ohashi, N.; Labhsetwar, N. K. J. Fluorine Chem. 2005, 126, 69. (b) Park, H.; Choi, W. J. Phys. Chem. B 2004, 108, 4086.

^{(26) (}a) Wang, Y. Q.; Sherwood, P. M. A. Chem. Mater. 2004, 16, 5427.
(b) Yu, J. C.; Yu, J.; Ho, W.; Jiang, Z.; Zhang, L. Chem. Mater. 2002, 14, 3808.

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Figure 3. XPS spectra of (a) Ti-16TFA-500 and (b) Ti-16TFA-900.



Figure 4. FTIR spectra of various TiO_2 samples [(a) *control* TiO_2 -500, (b) Ti-16TFA-500, (c) Ti-16TFA-700, and (d) Ti-16TFA-900].

this may be attributed to the surface-fluorinated Ti–F species.²⁷ Further, in the lower-wave-number region, a sharp band centered at 534 cm⁻¹ with a shoulder band at \sim 648 cm⁻¹ observed for the *control* TiO₂-500 represents the Ti–

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O-Ti phonon vibration.^{17a,27} In comparison, main bands at 281 639, 510, and 519 cm^{-1} can be observed for Ti-16TFA-500, 282 Ti-16TFA-700, and Ti-16TFA-900 samples, respectively. 283The band at 639 cm⁻¹ is ascribed to the surface Ti-F 284 bonds,²⁸ whereas the bands at 510 and 519 cm⁻¹ are 285consistent with a change in the chemical environment of the 286 titania matrix owing to the presence of a small amount of 287lattice Ti-F bonds.^{27b} The Ti-16TFA-800 sample showed a 288 similar pattern to Ti-16TFA-900 (Supporting Information 7). 289

In the sol-gel process, the hydrolysis (forced hydrolysis 290 in the present case) and polycondensation reactions occur 291 simultaneously as the sol was dried immediately after 24 292 hour aging. The drying process causes the formation of an 293 intimate gel of Ti(OOCCF₃)_{4-x}(OH)_x (Supporting Information 2941). The Ti-F bonds are only formed in the further condensa-295tion process (on calcination). This leads to the formation of 296 inlaid (deep) Ti-F bonds in the network structure. Those 297 Ti-F bonds, which are in the network structure, could not 298 be easily removed by heat treatment compared to the surface-299fluorinated ones. This explains the observations by TGA and 300 XPS. The mass loss shown by the Ti-16TFA gel up to 800 301 °C (above 400 °C) in TGA may be the mass loss of the 302 surface-fluorinated Ti-F species. The rest of the nominal 303 Ti-F bonds, which could not be quantified using XPS, may 304

^{(27) (}a) Li, Z. Thesis for doctor rerum naturalium (Dr. rer. nat.) im Fach Chemie; Mathematisch-Naturwissenschaftlichen Fakultät Humboldt-Universität zu Berlin, Berlin, 2005. (b) Ignat'eva, L. N.; Polishchuk, S. A.; Antokhina, T. F.; Buznik, V. M. Glass Phys. Chem. 2004, 30, 139. (c) Osabe, D.; Seyama, H.; Maki, K. Appl. Optics 2001, 41, 739. (d) Scarel, G.; Aita, C. R.; Tanaka, H.; Hisano, K. J. Non-Cryst. Solids 2002, 303, 50.

^{(28) (}a) Decken, A.; Nikiforov, G. B.; Passmore, J. Dalton Trans. 2006, 4328. (b) Cavalli, M.; Gnappi, G.; Montenero, A.; Bersani, D.; Lottici, P. P.; Kaciulis, S.; Mattogno, G.; Fini, M. J. Mater. Sci. 2001, 36, 3253.

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Table 2. Rate Constants of Various Degradation Reactions

sample	rate (min ⁻¹)
In UV light	t
Degussa P25	0.327
control TiO ₂ -700	0.089
control TiO ₂ -900	0.021
Ti-12TFA-800	0.168
Ti-12TFA-900	0.200
Ti-32TFA-800	0.154
Ti-32TFA-900	0.246
Ti-16TFA-700	0.147
Ti-16TFA-800	0.197
Ti-16TFA-900	0.426
Ti-16HOAc-700	0.012
Ti-16OxA-700	0.028
In Sunlight	
Ti-16TFA-900	0.041
control TiO ₂ -700	0.006

be the inlaid ones. The influence of such Ti-F bonds could
 however be detected using FTIR.

Photoactivity. Kinetic plots of various methylene blue 307 degradation experiments are presented in Figure 5. The 308 corresponding rate constants are presented in Table 2. A 309 complete degradation of MB was observed within 10 min 310 under UV light irradiation for the Ti-16TFA-900 sample. 311By contrast, the *control* TiO₂-900, which was in a 100% 312 rutile form, was found to be inactive up to a period of 6 h 313of UV irradiation. All the *control* samples took >2 h for 314 complete methylene blue degradation. These results indicate 315 that the TFA modification is highly effective in enhancing 316the photoactivity of TiO₂ at high temperatures. Furthermore, 317 the activity for Ti-16TFA samples was in the order 318 Ti-16TFA-900 > Ti-16TFA-800 > Ti-16TFA-700 > 319 Ti-16TFA-600 > Ti16TFA-500. These observations dem-320 onstrate the significant role of anatase crystallinity, surface 321322 properties, and the minimal oxygen vacancy concentration



Figure 5. Methylene blue degradation kinetics of various TiO_2 samples in the presence of UV light (a) and sunlight (b) [(a) Ti-16TFA-900, (b) Degussa P25, (c) Ti-16TFA-700, (d) *control* TiO₂-700, (e) Ti-16OxA-700, (f) *control* TiO₂-900, and (g) Ti-16HOAc-700; A, absorbance at 664 nm].

on the photoactivity of TiO₂. Similar experiments have also been conducted in Dublin sunlight, where the Ti-16TFA-900 showed a complete degradation of MB in 90 min (Figure 5b). On the other hand, the *control* TiO₂-700 could not degrade MB even after 10 h of solar light irradiation (Supporting Information 8).

Discussion

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Phase Evolution. Among the samples, Ti-16TFA-900 330 shows the highest anatase-to-rutile phase transformation 331 temperature (900 °C) compared to the low TFA samples and 332 the samples prepared with HOAc, OxA, and *control* TiO₂. 333 An increase in the TFA concentration (Ti-32TFA), however, 334 shows a similar effect on the phase transformation to that of 335 Ti-16TFA. The structural evolution of the samples-phase 336 formation and phase transformation-investigated by both 337 Raman and XRD demonstrate the effect of different modi-338 fiers. The anatase-to-rutile transformation involves the rear-339 rangement of the (TiO₆²⁻) octahedron.²⁹ The structure of 340 anatase consists of zigzag chains of octahedra, linked to each 341 other through shared edges, whereas in rutile, a linear chain 342of opposite edge-shared octahedra is found. Chains are 343 further linked to each other by sharing corner oxygen atoms 344 to form a 3D network. In our case, the metal cation (Ti^{4+}) is 345expected to undergo a coordination expansion to six when 346 chelated with TFA to form the independent Ti-(OOCCF₃)₄ 347 octahedral complexes.³⁰ Further, when hydrolysis and con-348 densation is initiated under the forced reaction conditions 349 (temperature-dependent hydrolysis and condensation), ini-350 tially, the independent octahedral complexes are hydrolyzed, 351 forming Ti(OOCCF₃)_{4-x}(OH)_x species. The next step is the 352 condensation of two octahedral complexes to form the vertex-353 shared octahedra.³⁰ Upon further heating, the condensation 354between the two vertex-shared octahedra leads to the 355 formation of an edge-shared octahedra, which is followed 356 by the linking up of a third octahedron. The spatial factors 357 offered by the trifluoroacetate complex may cause the joining 358 up of a third octahedron to the far corner of the dioctahedra, 359 thereby reducing the electrostatic repulsion.³¹ Subsequently, 360 when the temperature is sufficiently high, the decomposition 361 of the trifluoroacetate complex occurs. The faster thermal 362 decomposition (cleavage of Ti-OOCCF₃ bond) keeps up the 363 rate of segregation (condensation), and under such a fast rate, 364 the third octahedron will, preferentially, join to the existing 365 dioctahedral complex to form a right-angled trioctahedral 366 complex (anatase). This is perfectly in line with the previous 367 reports, where it was suggested that the faster reaction rate 368 promotes the formation of anatase rather than the thermo-369 dynamically favorable rutile structure.^{32,33} The thermal 370

(32) Yanagisawa, K.; Ovenstone, J. J. Phys. Chem. B 1999, 103, 7781.

^{(29) (}a) Matsumoto, Y.; Shono, T.; Hasegawa, T.; Fukumura, T.; Kawasaki, K.; Ahmet, P. Science 2001, 291, 854. (b) Garvie, R. C. J. Phys. Chem. 1978, 82, 218. (c) Shannon, R. D.; Pask, J. A. Am. Mineral. 1964, 49, 1707. (d) Depero, L. E.; Sangaletti, L.; Allieri, B.; Bontempi, E.; Marino, A.; Zocchi, M. J. Cryst. Growth. 1999, 198/199, 516. (e) Diebold, U. Surf. Sci. Rep. 2003, 48, 53.

⁽³⁰⁾ Livage, J.; Henry, M. In Ultrastructure Processing of Advanced Ceramics; Mackenzie, J. D.; Ulrich, D. R., Eds.; Wiley: New York, 1988; p 183.

^{(31) (}a) Gopal, M.; Chan, W. J. M.; De Jonghe, L. C. J. Mater. Sci. 1997, 32, 6001. (b) Yin, H.; Wada, Y.; Kitamura, T.; Kambe, S.; Murasawa, S.; Mori, H.; Sakata, T.; Yanagida, S. J. Mater. Chem. 2001, 11, 1694. (c) Li, Y.; Lee, N. H.; Hwang, D. S.; Song, J. S.; Lee, E. G.; Kim, S. J. Langmuir 2004, 20, 10838.

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Scheme 2. Schematic Representation of Anatase and Rutile Crystallization Events^a



^{*a*} (a) Anatase crystallization under the faster reaction conditions: the third octahedron, under the influence of fluorine, prefers to join to the existing dioctahedra by sharing an edge, forming a zigzag structure. (b) Anatase crystal structure after the removal of fluorine. (c) Rutile formation: the third octahedron preferably links up to the existing dioctahedra, forming a linear chain by sharing a pair of opposite edges, which is a thermodynamically favorable process. Under the high-temperature calcination process, the existing anatase clusters undergo a diffusional rearrangement to form the denser rutile crystals.

decomposition of trifluoroacetate species also causes the 371 372 fluorination of the remaining amorphous precipitate as well 373 as the existing anatase crystals (Scheme 2a). Under the fluorinated condition, the crystallization as well as the crystal 374 growth can be a slow process due to the fact that the 375fluorinated clusters may repel each other, slowing down the 376 reaction rate.³² The inhibition of crystallization and crystal 377 growth in such cases can be observed from the limitation of 378 the X-ray peak intensity as well as the slower line-narrowing 379 of the X-ray diffraction lines under the increasing calcination 380 temperature. Upon further heating, the fluorine atoms are 381 being preferentially eliminated (Scheme 2b), causing a faster 382 atomic/ionic diffusion. Such faster diffusion conditions are 383 384 favorable for the formation of a denser rutile structure (Scheme 2c). 385

The primary crystallite sizes calculated using the Scherrer 386 equation showed crystallite sizes of 26, 32, 33, 34 and 35 387 388 nm respectively for the Ti-16TFA-500, Ti-16TFA-600, Ti-16TFA-700, Ti-16TFA-800, and Ti-12TFA-900 samples 389 390 (Supporting Information 9). In addition, a direct dependence between the TFA concentration and rutile phase formation 391 can be noticed. The rutile phase formation occurs when the 392 anatase crystallite size was at 29, 31, 32, and 36 nm 393 respectively for the Ti-1TFA, Ti-4TFA, Ti-8TFA, and 394 Ti-12TFA samples, and for *control* TiO₂, it was at 26 nm. 395 The shift in the phase transformation temperature with TFA 396 addition can therefore be attributed to the presence of fluorine 397 in the system. As the TFA concentration increases, there is 398 a greater chance of the F atoms being trapped in the titania 399 matrix. Upon further heating, fluorine is eliminated easily 400 from the sample with low fluorine content, whereas the 401 elimination could be very slow from the samples with high 402 fluorine content, consistent with the high amount of deep-403

> (33) Meakin, P. In *Kinetics of aggregation and gelation*; Family, F.; Landau, D. P., Eds.; North Holland Physics Publishing: New York, 1984; p 91.

Chem. Mater. G

level trapped fluorine. As fluorine elimination and crystal 404 growth are simultaneous events, the crystallites have a chance 405 to grow to a greater extent in the high-TFA samples. Thus, 406 the critical size limit for the phase transformation of the 407 anatase crystals is shifted to higher crystallite size values 408 for high-TFA samples in the present case. By contrast, the 409 absence of fluorine in the *control* TiO₂ system caused a faster 410 temperature-dependent diffusional rearrangement, after the 411 initial anatase clustering, leading to the formation of a denser 412rutile structure at a comparatively lower temperature of 700 413 °C. Essentially, the fluorine substituted in the oxygen atomic 414 site inhibits the extensive Ti-O-Ti bridging (Scheme 2a). 415 These defect centers will also act as a barrier for oxygen 416 ion diffusion necessary for the grain growth and assisted 417phase transformation.³⁴ This clearly suggests the inhibiting 418 role of fluorine on the rutile phase nucleation, which may 419 only be commenced after the elimination of F atoms from 420 the structure. The higher bond enthalpy of Ti-O bonds (672) 421 \pm 9 kJ mol⁻¹) compared to the Ti–F bonds (569 \pm 33 kJ 422 mol⁻¹) may account for the preferential F elimination.³⁵ 423

It should be stated here that, even though the optimum 424 amount of fluorine necessary for the inhibition of rutile phase 425nucleation cannot be calculated quantitatively, the present 426 studies indicate that an initial concentration of 16 mol % 427TFA is sufficient to retain the anatase phase up to 900 °C. 428 This is further ascertained from the fact that a higher TFA 429 concentration (32 mol %) shows a similar effect as 16 mol 430 % TFA and a lower concentration (12 mol %) could not 431prevent the phase transformation up to 900 °C. It should 432also be noted that a $\pm 5\%$ error can be expected in 433determining the phase content. 434

Photocatalytic Activity. MB degradation experiments and 435the corresponding kinetic analyses data show the highest 436 activity for the Ti-16TFA-900 sample compared to the other 437 TFA samples (both lower temperature and various concen-438 tration TFA samples) and those prepared with HOAc, OxA, 439 and *control* TiO₂. Semiconductor photocatalytic reactions are 440 known to occur through (i) direct valence band hole (h_{VB}) 441 oxidation,³⁶ (ii) reactive oxygen species (namely, OH[•], O²⁻, 442and H_2O_2)^{36–37} assisted oxidation, and (iii) direct conduction 443 band electron (e_{CB}) reduction. The enhanced photocatalytic 444 activity^{36,38} and photoinduced hydrophilicity³⁹ of surface-445 fluorinated TiO₂ systems have been reported recently. 446

- (35) Lide, D. R. CRC Handbook of Physics and Chemistry, 84th ed.; CRC: Boca Raton, FL, 2003.
- (36) (a) Maurino, V.; Minero, C.; Mariella, G.; Pelizzetti, E. Chem. Commun. 2005, 2627. (b) Minero, C.; Mariella, G.; Maurino, V.; Pelizzetti, E. Langmuir 2000, 16, 2632. (c) Minero, C.; Mariella, G.; Maurino, V.; Vione, D.; Pelizzetti, E. Langmuir 2000, 16, 8964.
- (37) (a) Goto, H.; Hanada, Y.; Ohno, T.; Matsumura, M. J. Catal. 2004, 225, 223. (b) Cermenati, L.; Pichat, P.; Guillard, C.; Albini, A. J. Phys. Chem. B 1997, 101, 2650. (c) Kormann, C.; Bahnemann, D. W.; Hoffmann, M. R. Environ. Sci. Technol. 1988, 22, 798. (d) Hykaway, N.; Sears, W. M.; Morisaki, H.; Morrison, S. R. J. Phys. Chem. 1986, 90, 6663. (e) Morrison, S. R. Electrochemistry at Semiconductor and Oxidized Metal Electrodes; Plenum Press: New York, 1980; p 257. (f) Cai, R.; Kubota, Y.; Fujishima, A. J. Catal. 2003, 219, 214.
- (38) (a) Wang, R.; Hashimoto, K.; Fujishima, A.; Chikuni, M.; Kojima, E.; Kitamura, A.; Shimohigoshi, M.; Watanabe, T. *Nature* 1997, *388*, 431. (b) Tang, J.; Quan, H.; Ye, J. *Chem. Mater.* 2007, *19*, 116.

 ^{(34) (}a) Ding, D.; Liu, X. J. Mater. Res. 1998, 19, 2556. (b) Rao, C. N.;
 Rao, R. J. Phase transitions in solids; McGraw Hill: New York, 1978;
 p 82. (c) Zhang, H.; Banfield, J. F. J. Mater. Res. 2000, 15, 437.

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Recently, Maurio et al. reported that the fluorinated TiO₂ 447 systems increase the generation of adsorbed and free OH. 448 radicals.³⁹ Such an enrichment in the reactive species 449 concentration in suspension was associated with a consider-450able enhancement in the photocatalytic activity.³⁹ In addition, 451 F doping was also found to enhance the photocatalytic 452activity of TiO2.25a,40 Despite many studies, the exact 453mechanism of the photocatalytic reaction and the role of 454influencing parameters in such systems is still not clear. The 455 influence of F atoms in different systems is reported 456differently.^{25a,39,40} The present sol-gel method enabled the 457 preparation of both surface-fluorinated and F-doped TiO₂ 458 systems from a single process, allowing a direct and 459straightforward comparison of their activity. High-temper-460 ature heat treatment (900 °C) enabled the preparation of 461 F-doped TiO_2 (small amount of F) with high crystallinity 462 and microporosity, whereas the low-temperature heat treat-463 464 ment (500-700 °C) produced surface-fluorinated TiO₂. The Ti-16TFA-900 sample showed a higher photocatalytic activ-465ity compared to the surface-fluorinated TiO₂ in the present 466 study. 467

The photocatalytic activity of titania is mainly dependent 468 on factors such as accessible surface area, crystallinity, and 469 particle size.⁴¹ The microporous nature of Ti-16TFA-900 470 increases the accessibility of MB molecules to have maxi-471mum surface coverage by direct adsorption, which effectively 472enhances its reaction efficiency.^{25b} The lower activity of the 473low-temperature Ti-16TFA samples (activities in the order 474Ti-16TFA-500 < Ti-16TFA-600 < Ti-16TFA-700 < 475Ti-16TFA-800 < Ti-16TFA-900), in comparison, despite 476 their high surface accessibility (high surface areas), is 477478 ascribed to the high electronegativity of fluorine, which inhibits the interfacial charge transfer. In other words, the 479 steady increase in activity with an increase in calcination 480 temperature up to 900 °C may be attributed to the gradual 481 elimination of the fluorine incorporated in the titania matrix. 482 In addition, fluorine when incorporated into the titania matrix 483 increases the oxygen vacancy concentration. Subbarao et al. 484 reported the facilitating effect of oxygen vacancy on charge 485carrier recombination.⁴² The present observations are con-486 sistent with the report by Subbarao et al., where the high 487 photoactivity is obtained for the sample with a high crystal-488 489 linity, microporosity, and minimal oxygen vacancy concentration. The hydroxyl-radical-generating ability of the F 490

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atoms,39 in the case of the low-temperature samples, has been491nullified by the increase in oxygen vacancies. Therefore, the492presence of fluorine can be assumed to be detrimental to493the activity as it (i) reduces the rate of interfacial charge494transfer and (ii) creates more oxygen vacancies.495

Three factors have been identified which enhance the 496 activity of the Ti-16TFA-900 sample compared to the 497 surface-fluorinated TiO₂ samples in the present study. First 498 is the high anatase crystallinity of Ti-16TFA-900 compared 499 to the low-temperature calcined samples. Second is the 500 presence of minimal F content (minimal oxygen vacancy) 501 that reduces the charge carrier recombination process in 502 Ti-16TFA-900 compared to the low-temperature calcined Ti-503 16TFA samples. The presence of these nominal inlaid F 504 atoms increases the surface -OH groups, adsorbed OH. 505 radicals, and free OH[•] radicals (in solution). In case of the 506 low-temperature Ti-16TFA samples, the higher electrone-507 gativity of the surface-fluorinated F atoms will have more 508 influence in reducing the interfacial charge transfer compared 509to the generation of such reactive species. The relatively high 510adsorbing ability of surface F atoms (water and organic 511adsorption, especially MB) in such systems is nullified by 512the poor interfacial charge transfer to the adsorbed molecules. 513Finally, this material shows far more suitable surface 514properties, that is, a microporous nature of the Ti-16TFA-515900 sample with an enhanced probability of interfacial charge 516transfer. Despite having high surface area values, the low-517 temperature Ti-16TFA samples are less active due to the 518 factors described above. The hindering effect on rutile phase 519 nucleation by fluorine up to a temperature as high as 900 520°C was therefore helpful in attaining a highly crystalline and 521 microporous anatase TiO₂. The high photoactivity of the 522Ti-16TFA-900 sample is therefore ascribed to the synergistic 523effect of high crystallinity, microporosity, and minimum 524oxygen vacancy concentration, which could well be achieved 525by the high-temperature heat treatment. On the other hand, 526 the *control* TiO₂ samples are in the pure rutile form with 527 low porosity at these temperatures (700 and 900 °C) and 528 are therefore less active. It should be noted here that the 529red-shifting of the band gap absorption of *control* TiO₂ 530samples, which could have been favorable for the photoac-531tivity, has been nullified by the nonporous and noncatalytic 532 nature of the rutile phase. 533

Summary

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In summary, a simple and highly efficient procedure for 535 the preparation of high-temperature stable anatase (100% at 536900 °C) titania with a high photocatalytic activity is 537presented. Fluorine-assisted inhibition of rutile phase nucle-538 ation followed by the elimination of fluorine and subsequent 539commencement of rutile phase nucleation explains the high-540 temperature stability for the Ti-16TFA samples. The 541 Ti-16TFA-900 sample shows the highest photocatalytic 542activity in the presence of both UV light (λ 365 nm) and 543 sunlight, which is attributed to a synergistic effect of the 544 high crystallinity, microporosity, and a minimal oxygen 545vacancy concentration of anatase TiO₂. This intrinsic doping 546 approach is therefore proposed to be an effective methodol-547 ogy for replacing the conventional use of extrinsic cationic 548 dopants to obtain a high-temperature stable anatase phase. 549 The present sol-gel process to produce highly crystalline 550

^{(39) (}a) Yu, J. C.; Ho, W.; Yu, J.; Hark, S. K.; Iu, K. Langmuir 2003, 19, 3889. (b) Hattori, A.; Yamamoto, M.; Tada, H.; Ito, S. Chem. Lett. 1998, 707. (c) Hattori, A.; Shimota, K.; Tada, H.; Ito, S. Langmuir 1999, 15, 5422. (d) Yamaki, T.; Sumita, T.; Yamamoto, S. J. Mater. Sci. Lett. 2002, 21, 33. (e) Fujihara, S.; Kusakado, J.; Kimura, T. J. Mater. Sci. Lett. 1998, 17, 781.

^{(40) (}a) Wang, J.; Yin, S.; Zhang, Q.; Saito, F. J. Mater. Chem. 2003, 13, 2348. (b) Yamaki, T.; Umebayashi, T.; Sumita, T.; Yamamoto, S.; Maekawa, M.; Kawasuso, A.; Itoh, H. Nucl. Instrum. Methods Phys. Res., Sect. B 2003, 206, 254. (c) Ayllon, J. A.; Peiro, A. M.; Saadoun, L.; Vigil, E.; Domenech, X.; Peral, J. J. Mater. Chem. 2000, 10, 1911. (d) Vohra, M. S.; Kim, S.; Choi, W. J. Photochem. Photobiol., A 2003, 160, 55.

^{(41) (}a) Harada, H.; Ueda, T. Chem. Phys. Lett. 1984, 106, 229. (b) Nishimoto, S. I.; Ohtani, B.; Kajiwara, H.; Kagiya, T. J. Chem. Soc., Faraday Trans. 1985, 1, 61. (c) Bickley, R. I.; Carreno, T. G.; Lees, J. S.; Palmisano, L.; Tilley, R. J. D. J. Solid State Chem. 1991, 92, 178. (d) Xu, N.; Shi, Z.; Fan, Y.; Dong, J.; Shi, J.; Hu, M. Z.-C. Ind. Eng. Chem. Res. 1999, 38, 373.

⁽⁴²⁾ Subbarao, S. N.; Yun, Y. H.; Kershaw, R.; Dwight, K.; Wold, A. Inorg. Chem. 1979, 18, 488.

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anatase TiO_2 stable up to a temperature as high as 900 °C therefore has fundamental as well as technological importance.

Abbreviations. TTIP, titanium tetraisopropoxide; TFA,
trifluoroacetic acid; HOAc, acetic acid; OxA, oxalic acid;
MB, methylene blue.

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Supporting Information Available: FTIR data showing the 566 chelation of TFA (Supporting Information 1), XRD patterns of Ti-567 12TFA and Ti-32TFA samples calcined at 900 °C (Supporting 568 Information 2), N₂ adsorption and desorption isotherms of a 569 Ti-16TFA-900 sample (Supporting Information 3), diffuse reflec-570tance spectra (Supporting Information 4), high-resolution XPS 571spectra of Ti-TFA-800 and Ti-16TFA-900 (Supporting Information 5725), TGA analysis graphs (Supporting Information 6), FTIR spectra 573(Supporting Information 7), extensive UV-vis spectral character-574ization data (Supporting Information 8), and a table showing the 575crystallite sizes of samples (Supporting Information 9). This material 576is available free of charge via the Internet at http://pubs.acs.org. 577

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